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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/717,971	11/21/2003		Heine Melle Mulder	081468-0306721	8008
909	7590	03/09/2005		EXAMINER	
PILLSBUR	Y WINT	THROP, LLP	MATHEWS, ALAN A		
P.O. BOX 10	0500				
MCLEAN,	VA 2210)2	ART UNIT	PAPER NUMBER	
				2851	
				DATE MAILED: 03/09/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)					
	10/717,971	MULDER ET AL					
Office Action Summary	Examiner	Art Unit					
	Alan A. Mathews	2851					
The MAILING DATE of this communication app	pears on the cover sheet with the	correspondence address					
Period for Reply	VIO OET TO EVEIDE AMONTU	(O) FDOM					
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be till by within the statutory minimum of thirty (30) da will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONI	mely filed ys will be considered timely. n the mailing date of this communication. ED (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s) filed on							
•-	—· s action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
,	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4)⊠ Claim(s) <u>1-18</u> is/are pending in the application							
· · · · · · · · · · · · · · · · · · ·	4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6) Claim(s) <u>1-3,5-7,10-12 and 14-18</u> is/are reject							
7)⊠ Claim(s) <u>4,8,9 and 13</u> is/are objected to.							
8) Claim(s) are subject to restriction and/o	or election requirement.						
Application Papers							
9) The specification is objected to by the Examine	er.						
·) The drawing(s) filed on <u>23 November 2003</u> is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the							
Replacement drawing sheet(s) including the correc	tion is required if the drawing(s) is ob	pjected to. See 37 CFR 1.121(d).					
11) The oath or declaration is objected to by the Ex	xaminer. Note the attached Office	Action or form PTO-152.					
Priority under 35 U.S.C. § 119							
12)⊠ Acknowledgment is made of a claim for foreign a)⊠ All b)□ Some * c)□ None of:	n priority under 35 U.S.C. § 119(a)-(d) or (f).					
1. ☐ Certified copies of the priority document	ts have been received.						
2. Certified copies of the priority document		ion No					
3. Copies of the certified copies of the prior							
application from the International Burea	u (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list	of the certified copies not receive	ed.					
Attachment(s)	_						
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) 🔲 Interview Summan Paper No(s)/Mail D						
3) 🔯 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	5) Notice of Informal I	Patent Application (PTO-152)					
Paper No(s)/Mail Date <u>11//21/03</u> .	6) [] Other:						

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-3, 5, 7, 10, 11, 12, 14, and 16-18 are rejected under 35 U.S.C. 102(b) as being anticipated by Takahashi (U. S. Patent No. 6,040,894). Takahashi discloses in figure 6 and column 4, lines 9-33, column 7, lines49-67, and column 8, lines 1-11, a radiation system to provide a projection beam of radiation, the radiation system comprising an illumination system including source 1 and elements 2, 3, 4, 5, 6, 7, and 8 for defining a position dependent intensity distribution of the beam in the pupil plane 14. The intensity distribution is position dependent, since adjusting the position of light source 1 by adjusting mechanism T1, changes the intensity distribution (see column 8, lines 9 and 10). Changing the position of the light source would also change angles of the light beam. The reticule 12 (patterning structure) would be on a reticule table. The wafer or substrate 15 would be on a substrate table. Beam splitter 9 in figure 6 splits off an auxiliary beam. Detector 100 detects information about a position intensity distribution corresponding to the pupil plane 14. With respect to claim 2, the computing means 18 is considered to be the controller, and the position of source 1 with respect to reflector 2 is considered to be the optical element. With respect to claim 17, the integrator 6 homogenizes the

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intensity distribution. With respect to claim 18, regulating the intensity distribution at the pupil plane would regulate the intensity distribution at the substrate.

3. Claims 1, 2, 3, 5-7, 10-12, 14, 15 – 18 are rejected under 35 U.S.C. 102(b) as being anticipated by Shiozawa (U. S. Patent No. 5,684,567). Shiozawa discloses in figures 1 and 2 and column 4, lines 6-41, a radiation system, a reticule stage 15 (support structure) for reticule 14 (patterning structure), and a substrate table 19 for substrate 17. Figure 1 and column 4, lines 6-41 also discloses a beam splitter 11 splitting off an auxiliary beam, and detector 12 to detect information about the intensity distribution. Element 20 changes the position of integrator 7 to change the light intensity distribution (see column 5, lines 6-23). With respect to claim 2, the optical element would be integrator 7, and the parameter would be its position. It is also noted that figures 14A, 14B, and 15A has an axicon (optical element) 21 and 22 for changing the light intensity distribution, which would be angular dependent (see column 6, lines 65-67, and column 7, lines 1-17). In this case, the parameter would be the distance between optical element 21 and 22. The controller is what operates 20 or the spacing between elements 21 and 22. With respect to claims 6 and 15, the axicon 21 and 22 would be a deconvolution unit.

Allowable Subject Matter

4. Claims 4, 8, 9, and 13 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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Conclusion

5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The patents cited in the PTO-1449 are cited for the same reasons they were cited in Applicants IDS. The patent to Wangler et al. is cited to show the U.S. equivalent to EP 0687956.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alan A. Mathews whose telephone number is (571) 272-2123. The examiner can normally be reached on Monday through Friday from 8:00 AM to 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Judy Nguyen can be reached on (571) 272-2258. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Alan A. Mathews

Primary Examiner

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